	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	1723	((mask or reticle) near4 stage) and ((wafer or substrate) near4 stage)	USPAT	2002/09/15 17:03
2	BRS	L2	848	or correct\$4) with (piezoelectric or piezo-electric)	USPAT	2002/09/15 17:04
3	BRS	L4	1805	((mask or reticle) near4 stage) and ((wafer or substrate) near4 stage)	USPAT	2002/09/15 17:03
4	BRS	L3	4	1 and 2	USPAT	2002/09/15 17:03
5	BRS	L5	971	(vibration or deformation or deform\$3 or vibrat\$3) with (damp\$3 or isolat\$4 or suppress\$3 or compensat\$4 or correct\$4) with (piezoelectric or piezo-electric)	USPAT	2002/09/15 17:08
6	BRS	L6	4	4 and 5	USPAT	2002/09/15 17:04
7	BRS	L7	47131	(vibration or deformation or deform\$3 or vibrat\$3) with (damp\$3 or.isolat\$4 or suppress\$3 or compensat\$4 or correct\$4)	USPAT	2002/09/15 17:06
8	BRS	L8	3942	(damp\$3 or isolat\$4 or suppress\$3 or compensat\$4 or correct\$4) with (piezoelectric or piezo-electric)	USPAT	2002/09/15
9	BRS	L9	10	7 and 8 and 4	USPAT	2002/09/15 17:07
10	BRS	L10	6	9 not 6	USPAT	2002/09/15 17:07
11	BRS	L11	36344	(vibration or vibrat\$3) with (damp\$3 or isolat\$4 or suppress\$3 or compensat\$4 or correct\$4)	USPAT	2002/09/15 17:08
12	BRS	L12	1286	11 and 8	USPAT	2002/09/15 17:08
13	BRS	L13	4	12 and 355/\$.ccls.	USPAT	2002/09/15 17:08

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